## **EUROPEAN PATENT OFFICE**

## **Patent Abstracts of Japan**

PUBLICATION NUMBER

63112646

**PUBLICATION DATE** 

17-05-88

APPLICATION DATE

29-10-86

APPLICATION NUMBER

61255835

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INT.CL.

C08L 51/04 //(C08L 51/04 , C08L 83:04 )

TITLE

HIGH-GLOSS, IMPACT-RESISTANT POLYSTYRENE RESIN COMPOSITION

ABSTRACT :

PURPOSE: To form an impact-resistant polystyrene resin compsn. which is inexpensive, has well-balanced properties with respect to qualitites such as colorability, impact strength and rigidity and gives molded forms having excellent appearances, by combining a rubber-modified polystyrene having a specified microstructure with a polydimethylsiloxane.

CONSTITUTION: This impact-resistant polystyrene resin compsn. contains a rubber-modified polystyrene (A) and 0.005~0.8wt% (based on the amount of the compsn.) poly-dimethylsiloxane (B). Said polystyrene is one wherein a rubbery polymer in the form of particles is dispersed and the dispersed particles have such a particle size distribution that they have two peaks consisting of fine particle part and large particle part wherein the fine particle part has an average particle size of 0.1~0.6μ and the large particle part has an average particle size of 0.7~2.0µ. 20~95wt% rubber in the compsn. is composed of fine particles and 5~80wt% thereof is composed of large particles.

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